

# The Einzel Lens Longitudinal Chopper

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ECRIS 2012

*24<sup>th</sup> September – 27<sup>th</sup> September 2012  
in Sydney*

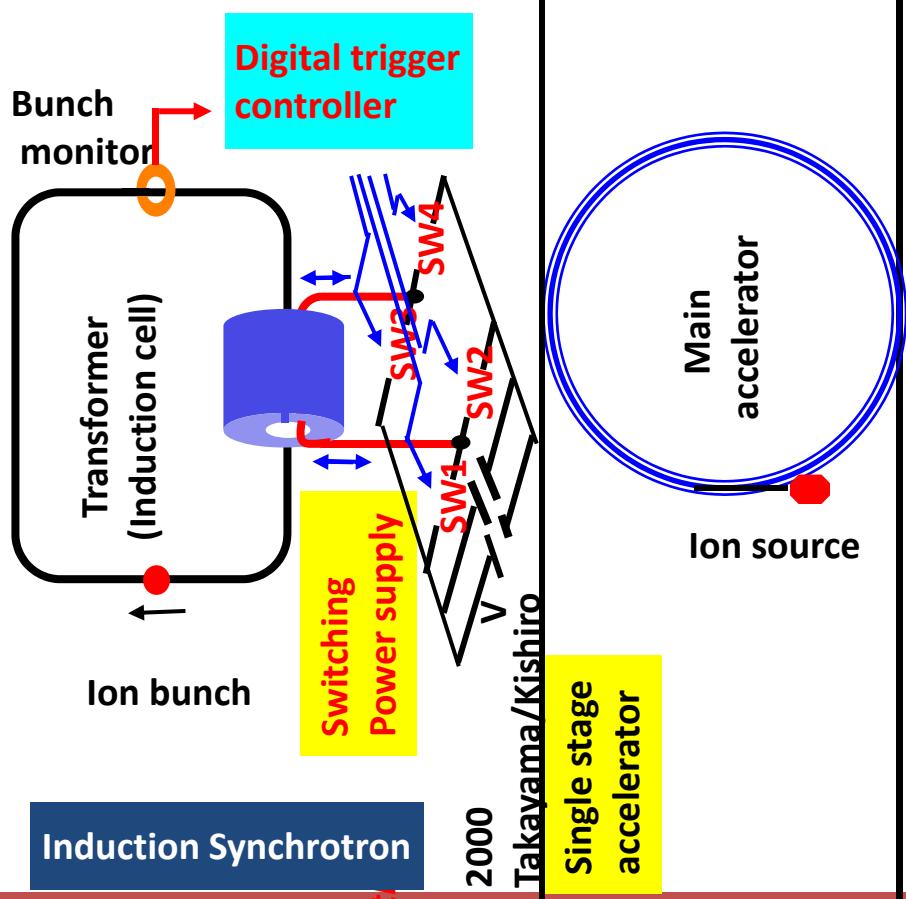
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Key components (ECRIS, Einzel lens, ....)**
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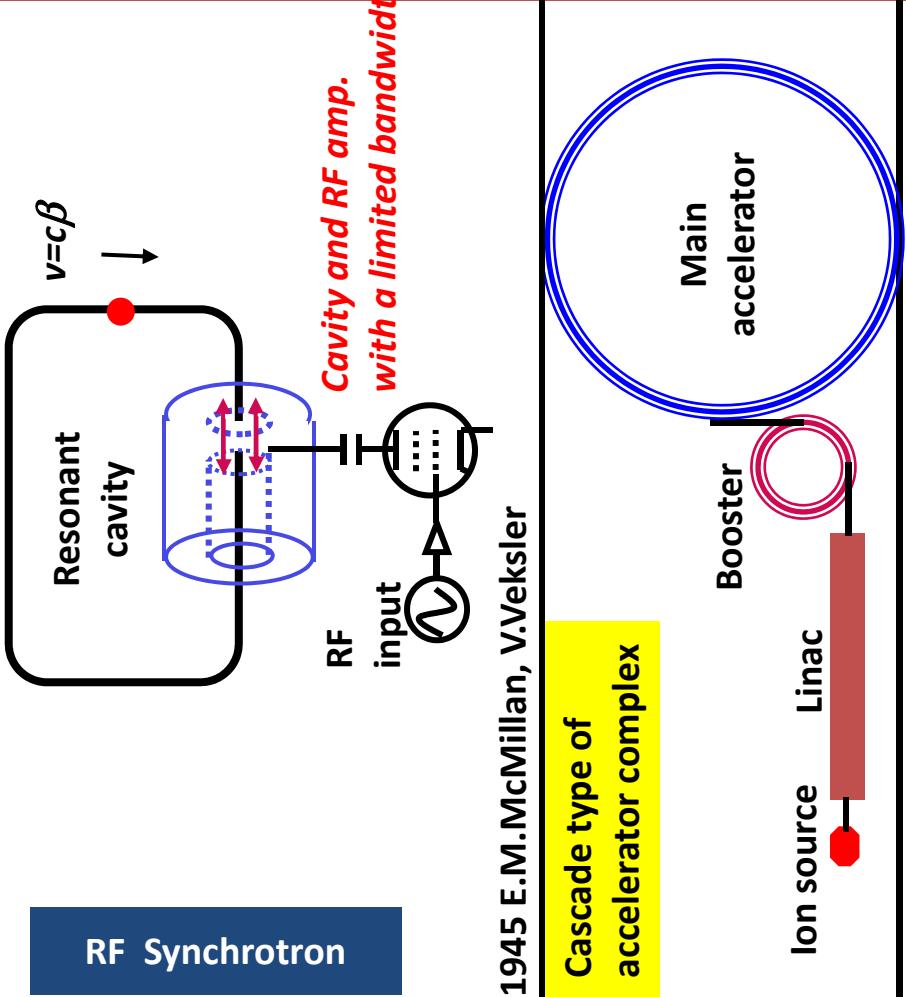
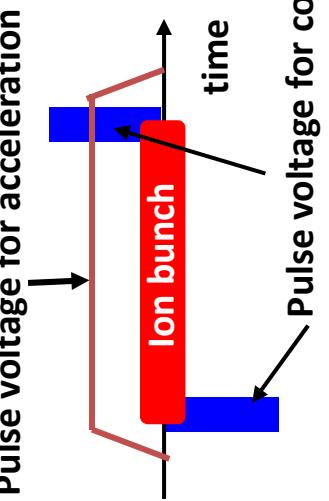
## Reference:

- [1] K.Takayama and R.Briggs (*Eds.*), “**Induction Accelerators**” (Springer, 2010)
- [2] T.Iwashita *et al.*, “**KEK Digital Accelerator**”,  
*Phys. Rev. AB-ST* **14**, 071301 (2011).
- [3] **Leo K.W. et al., “Permanent Magnet ECRIS for the KEK Digital Accelerator”,  
ECRIS2010 ,TUPOT15 (2010)**
- [4] T.Adachi *et al.*, “**A Solid-state Marx Generator driven Einzel lens Chopper**”,  
*Rev. Sci. Inst.* **82**, 083305 (2011).
- [5] **Leo K.W. et al., “Einzel Lens Chopper and Behavior of the Chopped Beam  
in the KEK Digital Accelerator”,  
Phys. Rev. ST-AB (2012), to be published.**

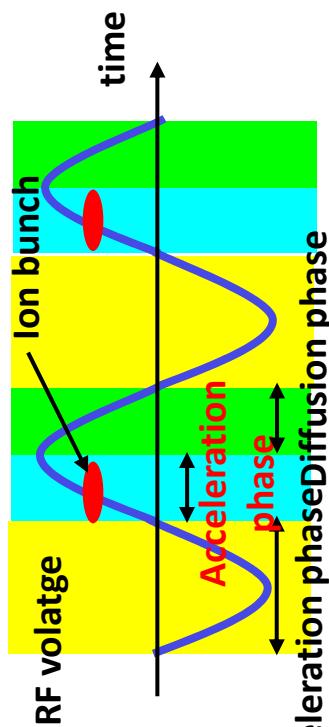
# Characteristics of Induction Synchrotron (Digital Accelerator)



*Functionally separated acceleration/confinement  
-> increasing a freedom of beam handling*



*Functionally combined acceleration/confinement ->  
increase in the local density -> limit on a beam current*



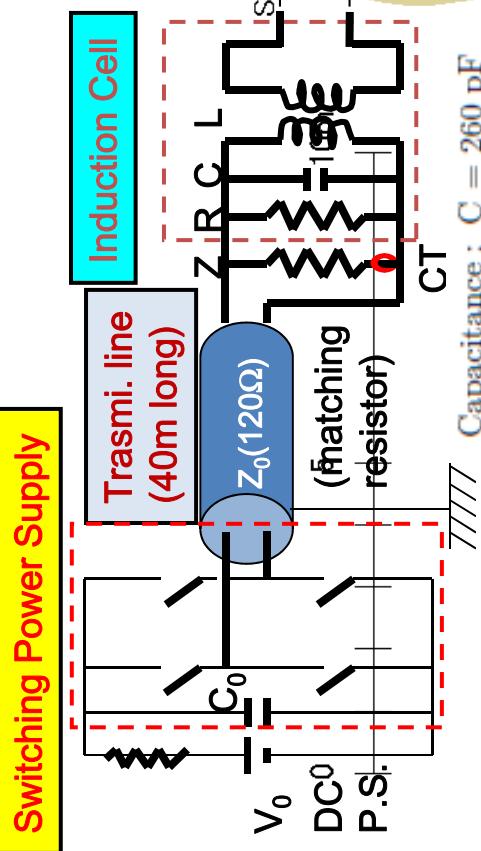
3  
**Pulse voltage for confinement**

# KEK Digital Accelerator (Rapid Cycle Induction Synchrotron)

T. Iwashita *et al.*, "KEK Digital Accelerator", Phys. Rev. ST-AB 14, 071301 (2011).

4

## Equivalent Circuit for Induction Acceleration System



Capacitance :  $C = 260 \text{ pF}$   
Resistance :  $R = 330 \Omega$   
Inductance :  $L = 110 \mu\text{H}$

S8

QD4

QD3

B3

QF3

B2

QF1

B1

QD6

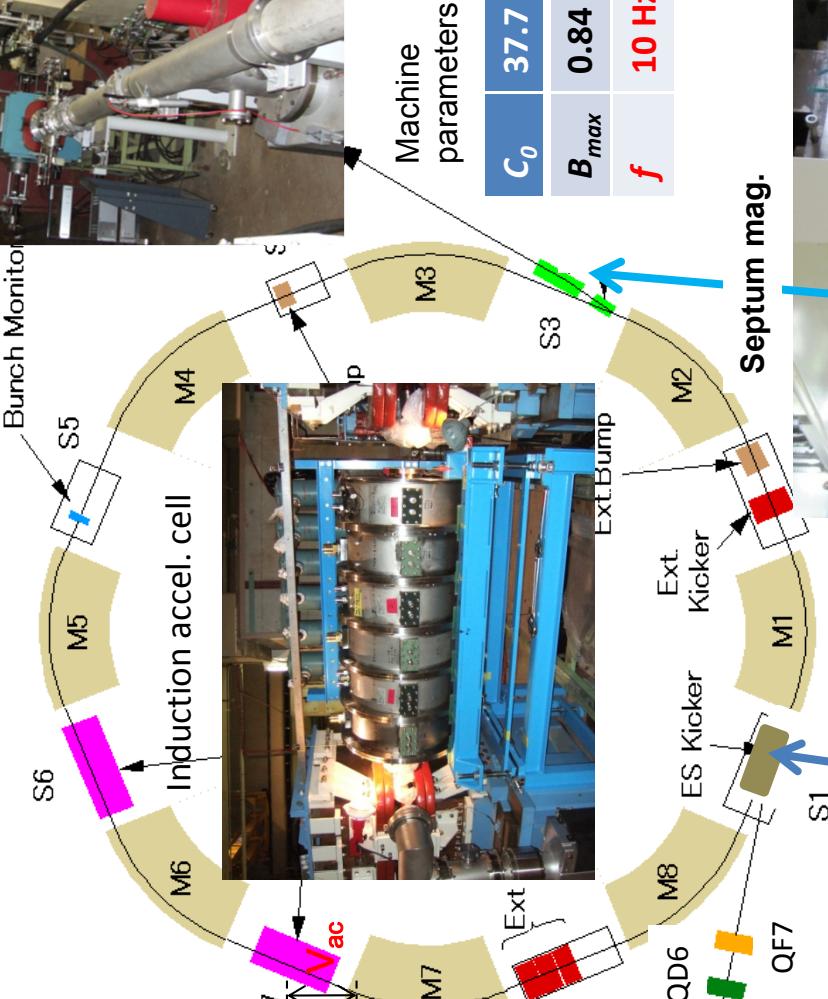
M8

ES Kicker

Ext. Kicker

Ext. Ext.

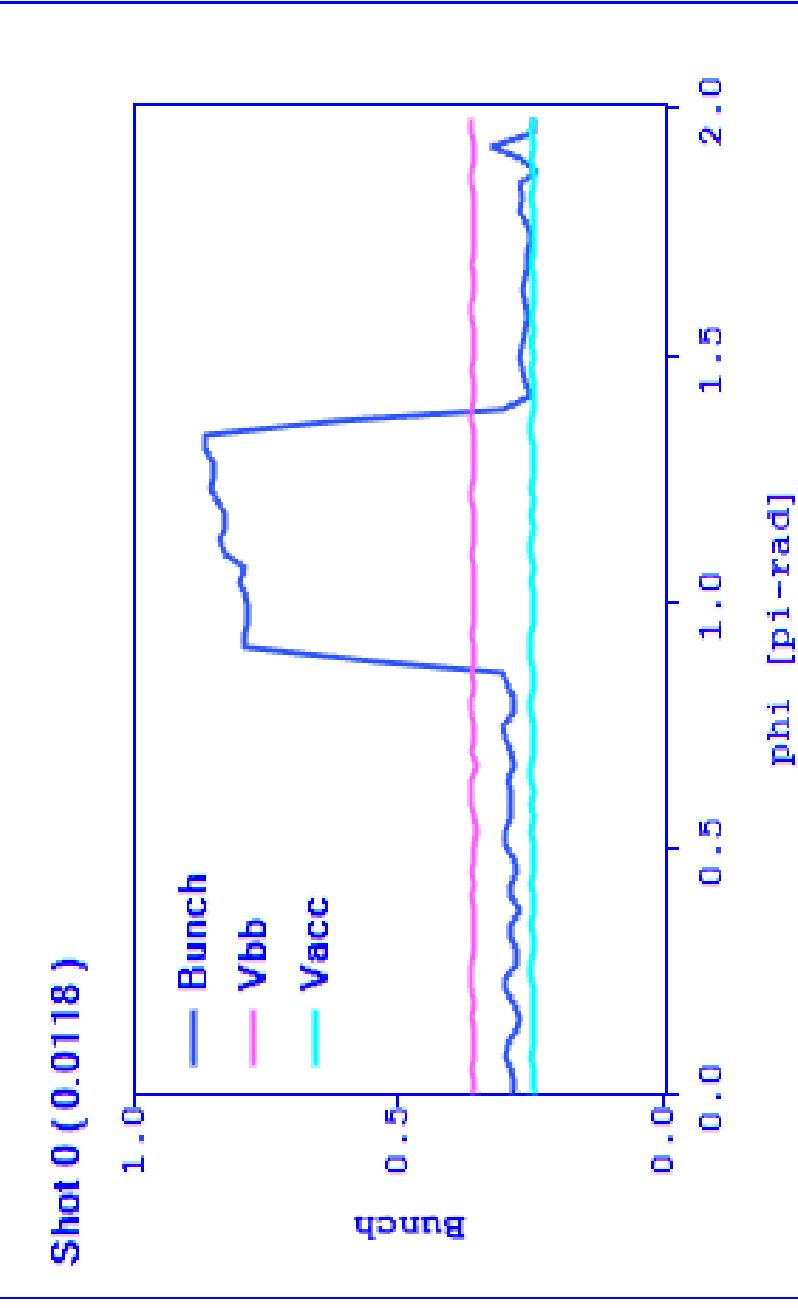
ECRIS & 200 kV HVP



# Beam Commissioning (4): Demonstration of He1+ Acceleration (Preliminary)

Turn No Time after injection

Shot 0 (0.0118)



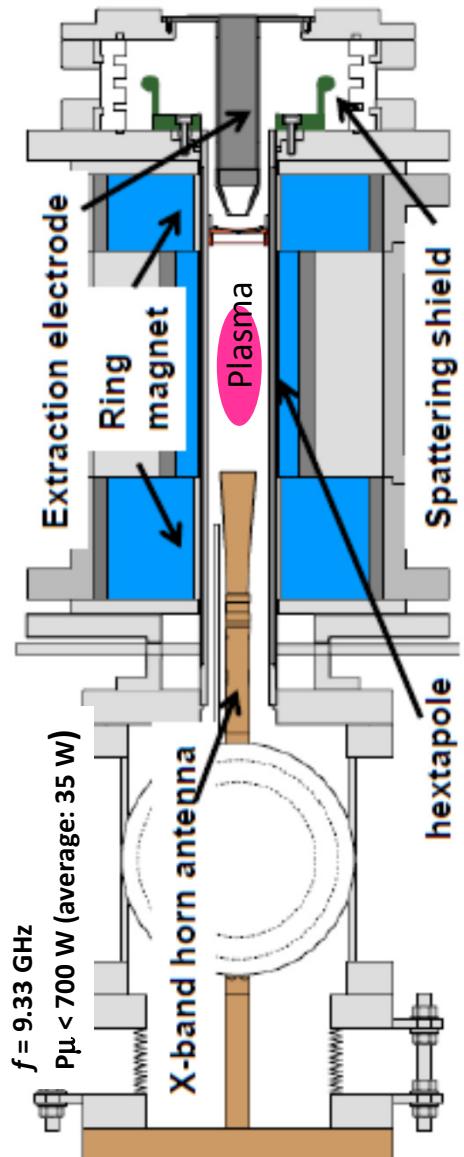
He ion bunch signal  
Barrier voltage pulse  
Acceleration voltage pulse

## Provided ion species and parameters at KEK Digital Accelerator

Ion source	ion	energy	Particle number/sec
ECR Ion Source	H, He, C, N, O, Ne, Ar	< 140 MeV/au, 200MeV	<10 <sup>10</sup>
Laser Ablation Ion Source	Xe, Fe, Cu, Ag, Au	< 70 Mev/au	< 10 <sup>9</sup>

TABLE I. Parameters of KEK-DA ECRIS

# ECR Ion Source : Schematic and Output

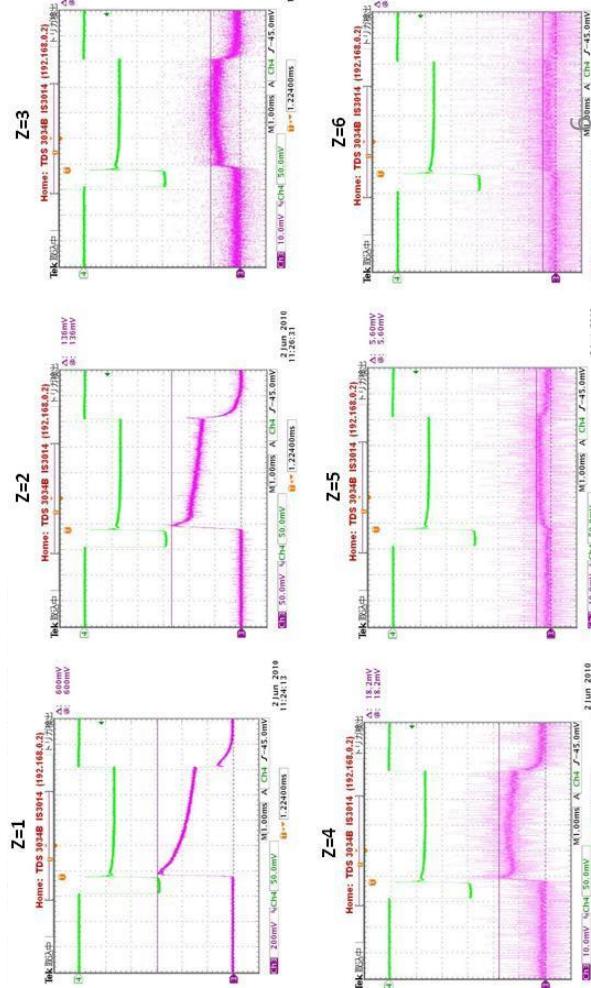


**Properties:**  
**Permanent magnets**  
**10 Hz pulse mode operation**

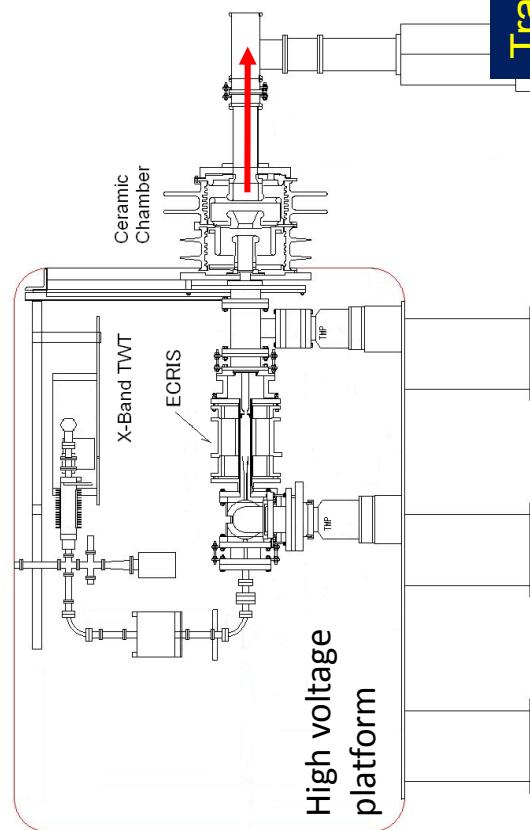


**No power for guiding magnets**  
**No cooling water**

$\text{He}^{2+}, \text{N}^{x+}, \text{O}^{5+}, \text{Ne}^{5+}, \text{Ar}^{5+}$  at this moment



## Ne Ion Pulse



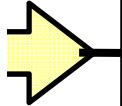
TrapCAD was helpful to understand some physics there.

# Necessity of Chopper and Possible Schemes

Why we need a Chopper?

1 turn injection < 10  $\mu$ sec  
A long pulse from ECRIS ~ 2 - 5 msec

What type is desired?



High energy operation

- High energy x-ray
- Out-gassing
- Secondary  $e^-$
- Higher cost

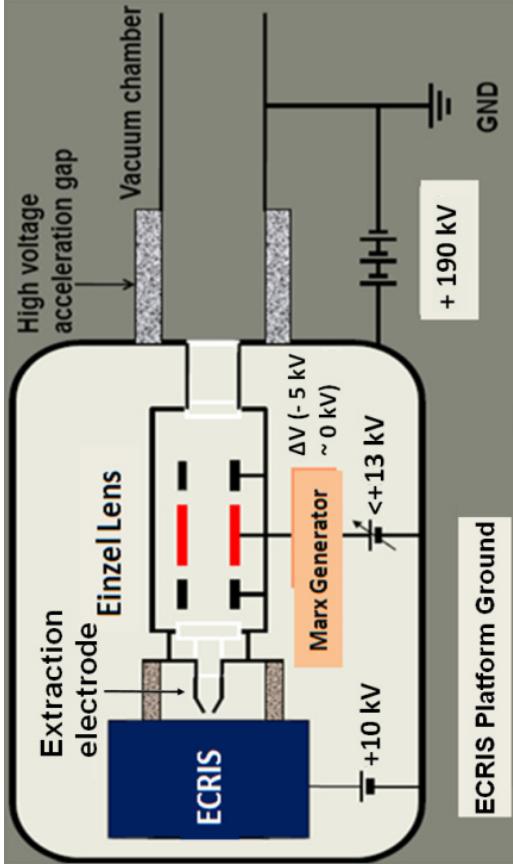
Low energy operation

- Low energy x-ray
- Reduced out-gassing
- Reduced secondary  $e^-$
- Lower cost

Transverse chopper

- Extra head
- Extra space

Longitudinal chopper



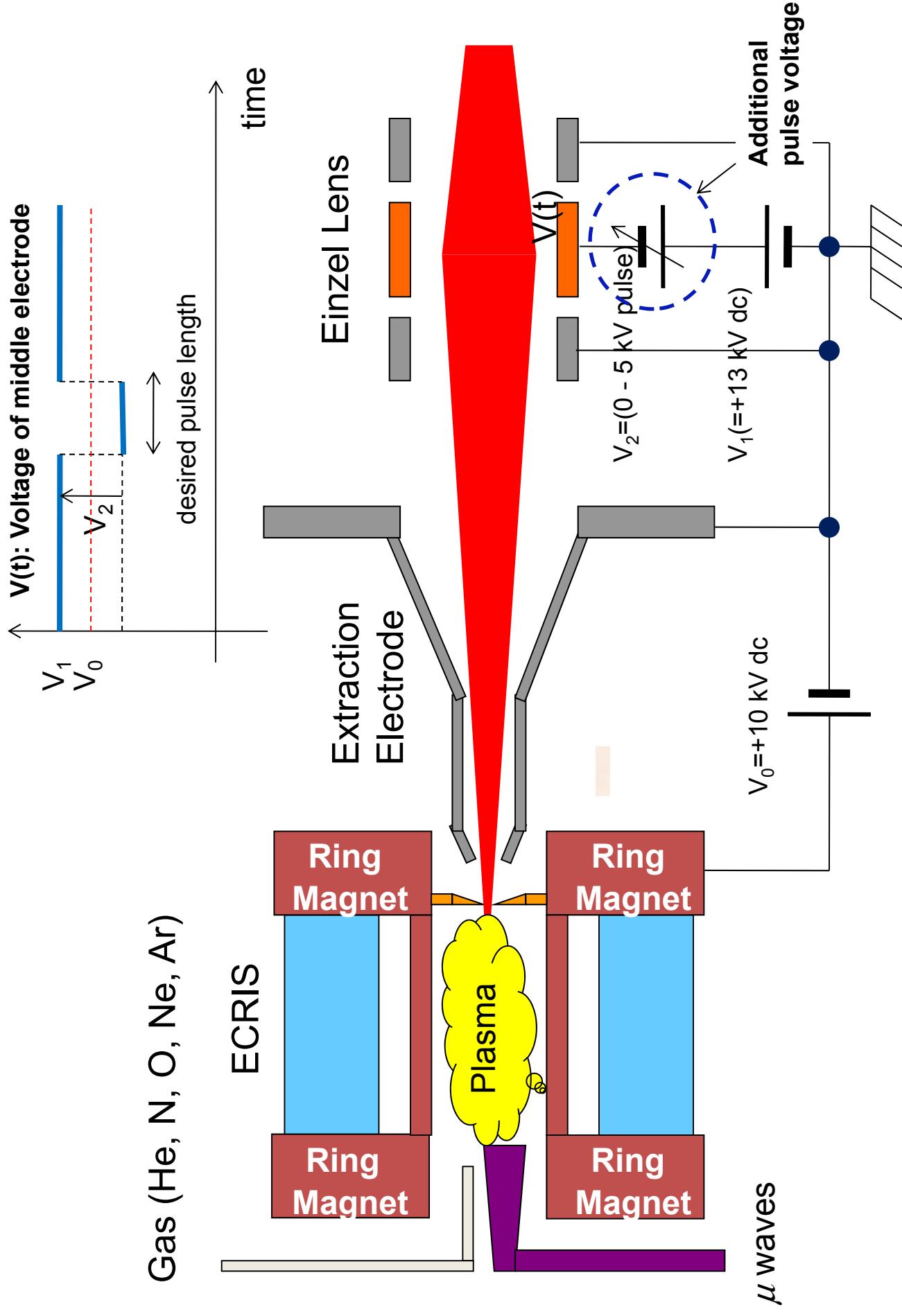
Einzel lens chopper

- Existing EL electrode is available
- as chopper head
- No extra space

Modulation of ECRIS extraction voltage

- Large stray capacitance -> sharp pulse isn't expected

# Principle of Einzel Lens Chopper



# Verification of the Idea by Simulation and Experiment (static)

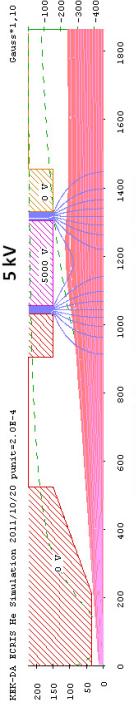
Inside

extraction electrode Einzel lens region



1. 1.5E-4 A, crossover at Z= 6, P=12.18 mesh units

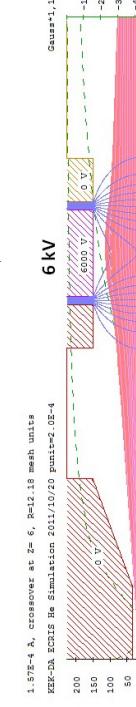
KER-DA ECRIS He Simulation 2011/10/20 punto\*2.0E-4



IGRN-7.067(C).R.Bercker - RUN 04/10/12\*002, file=KERDA2.in

1. 1.5E-4 A, crossover at Z= 6, P=12.18 mesh units

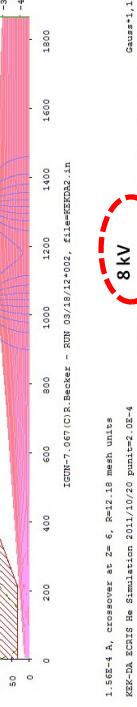
KER-DA ECRIS He Simulation 2011/10/20 punto\*2.0E-4



IGRN-7.067(C).R.Bercker - RUN 03/18/12\*002, file=KERDA2.in

1. 1.0E-5 A, crossover at Z= 6, P=12.18 mesh units

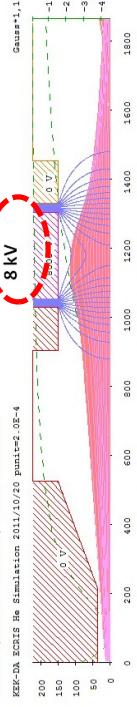
KER-DA ECRIS He Simulation 2011/10/20 punto\*2.0E-4



IGRN-7.067(C).R.Bercker - RUN 03/18/12\*002, file=KERDA2.in

1. 0.9E-5 A, crossover at Z= 1123, P=9.09 mesh units

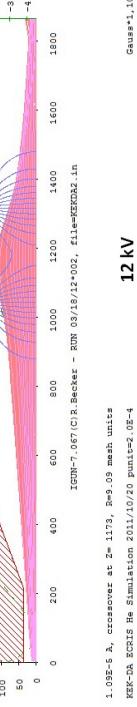
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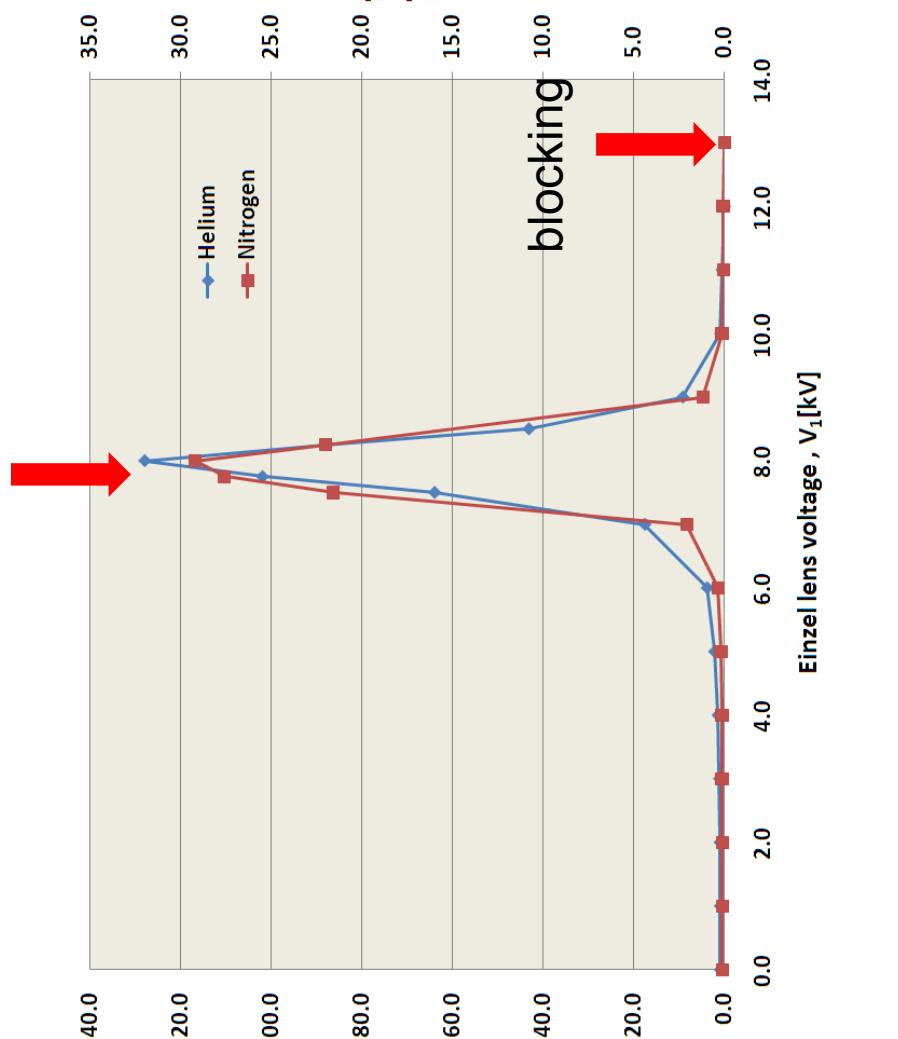
1. 4.7E-6 A, crossover at Z= 1126, P=6.85 mesh units

KER-DA ECRIS He Simulation 2011/10/20 punto\*2.0E-4



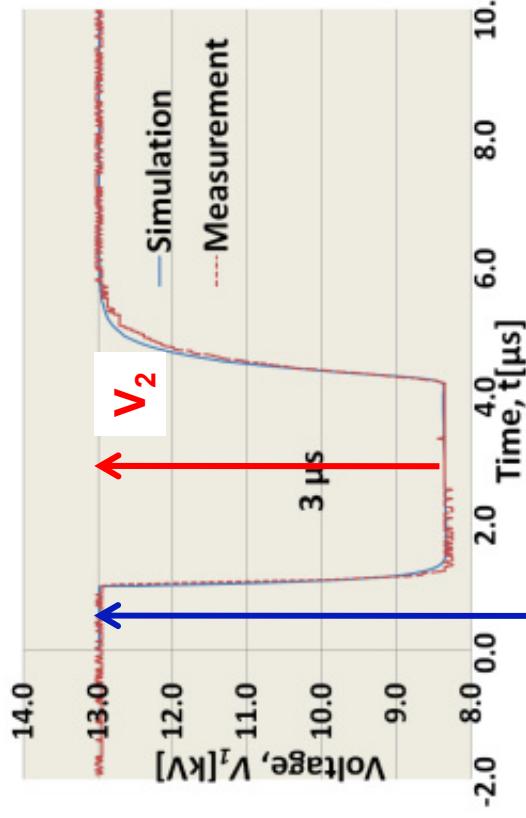
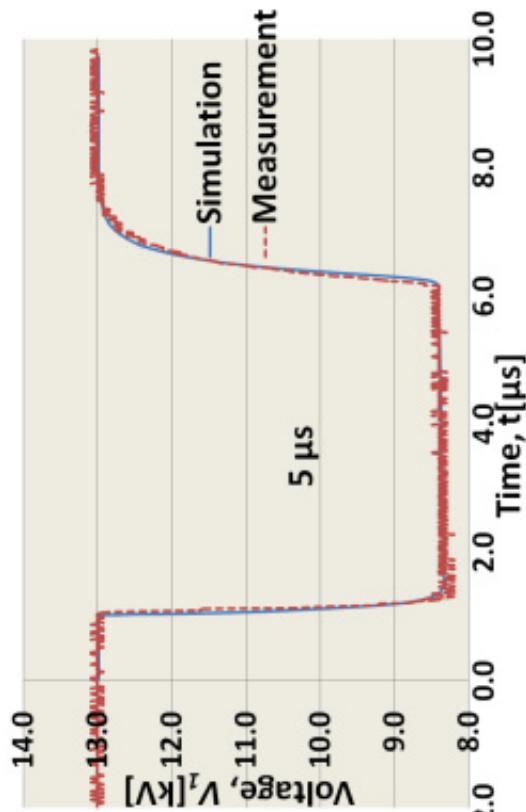
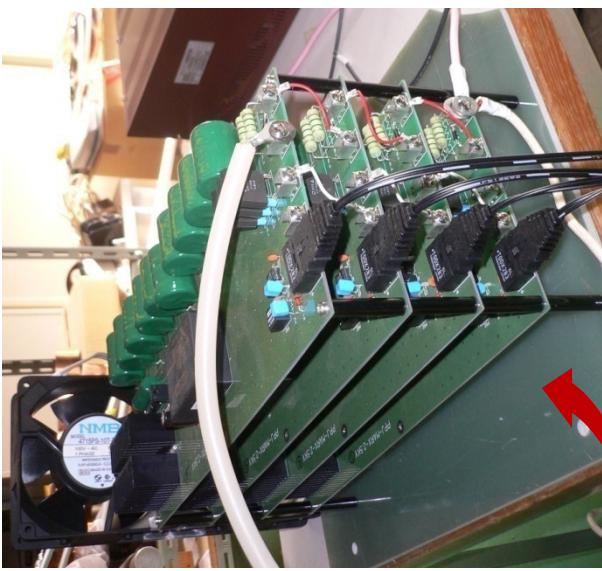
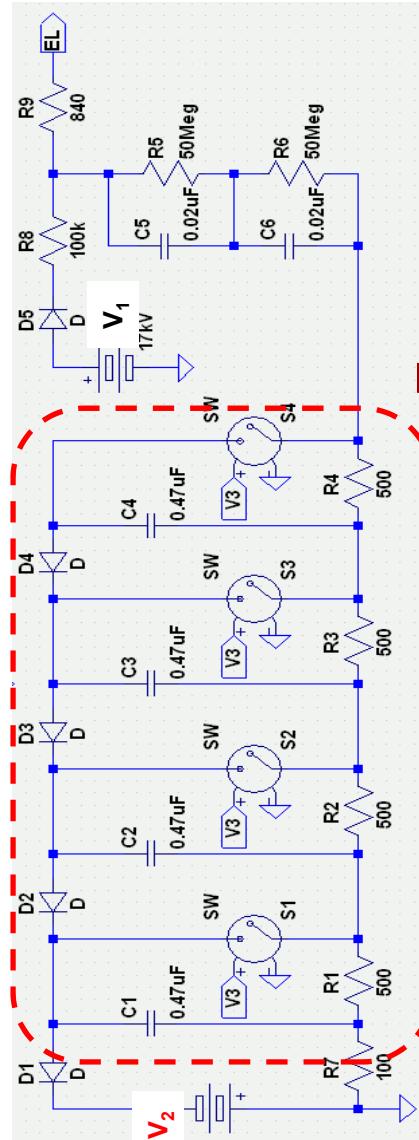
IGRN-7.067(C).R.Bercker - RUN 03/18/12\*002, file=KERDA2.in

Matching for beam transport

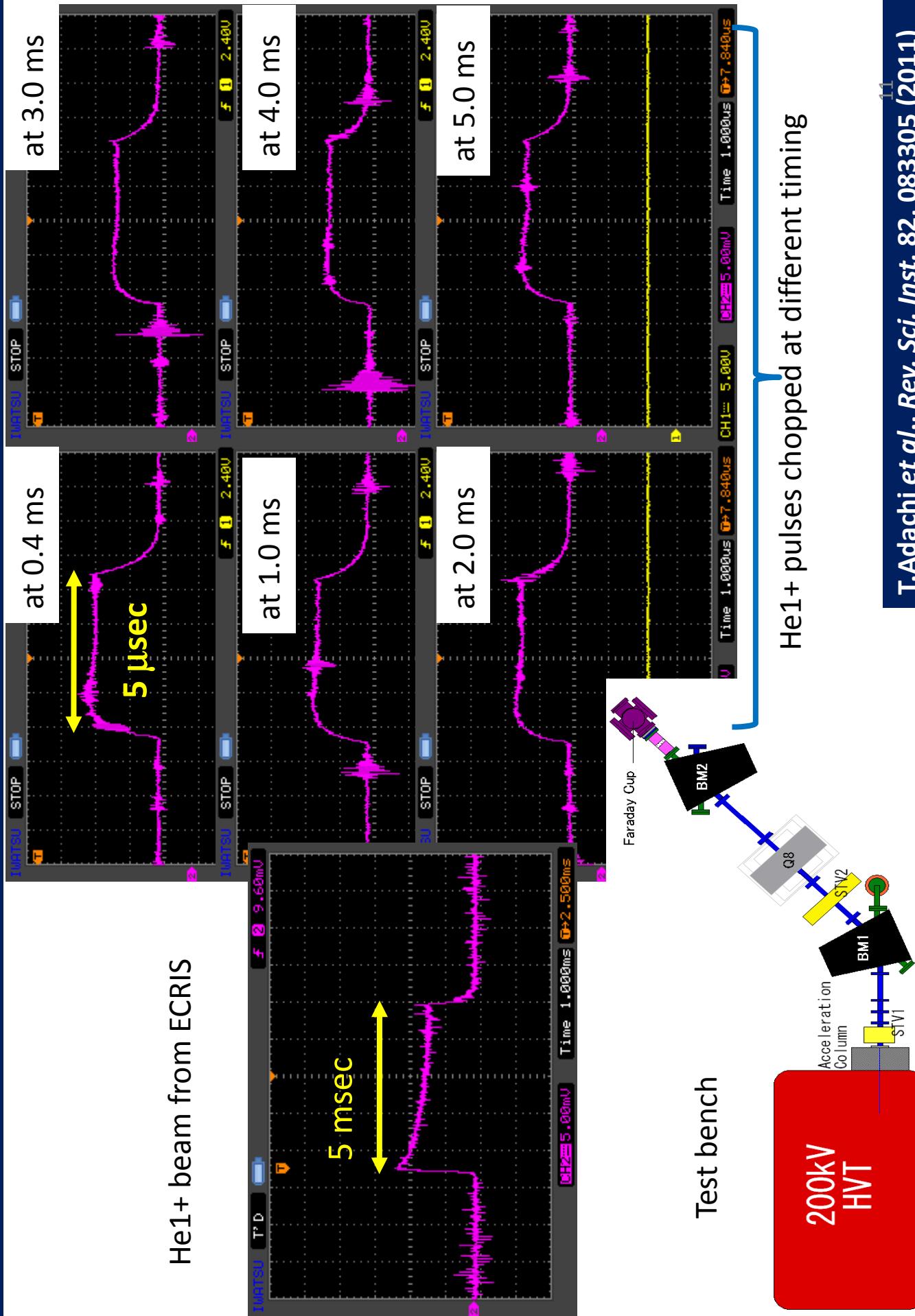


# Solid-state Marx Generator as a Pulse Power Supply for the Chopper

## FET switch driven 4 stages Marx generator



# Chopping Experiments

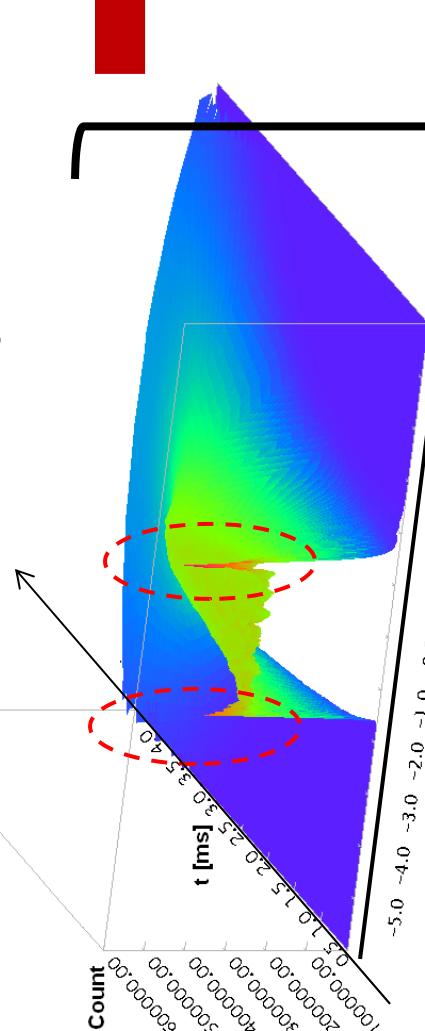


# Behavior of a Chopped Beam Pulse in the Ring and its Characteristics

Free run (no acceleration and no confinement)

Beam intensity

time after injection

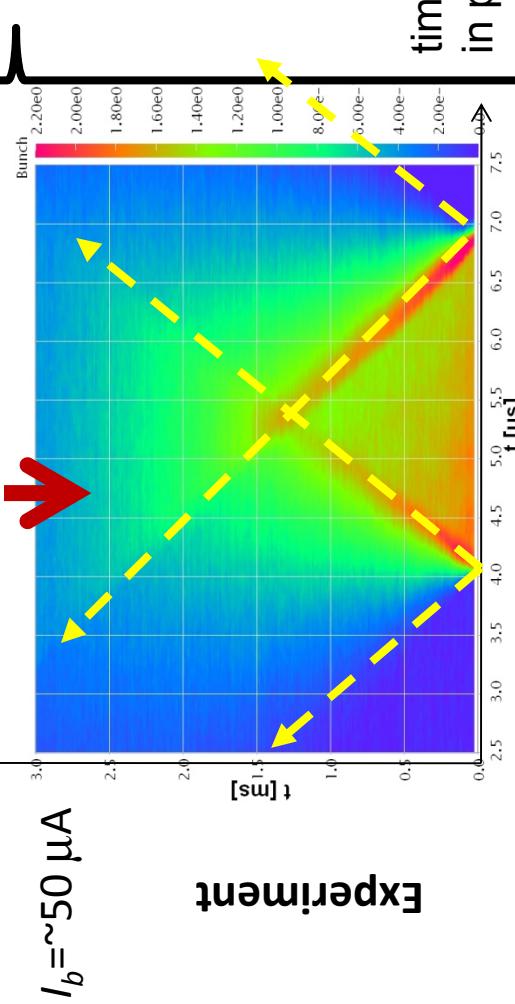


Time after injection      *Projection*

tail

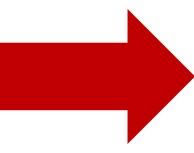
time in pulse

head



Experiment

- Sharp peak at head/tail of pulse
- Different components in Momentum spread

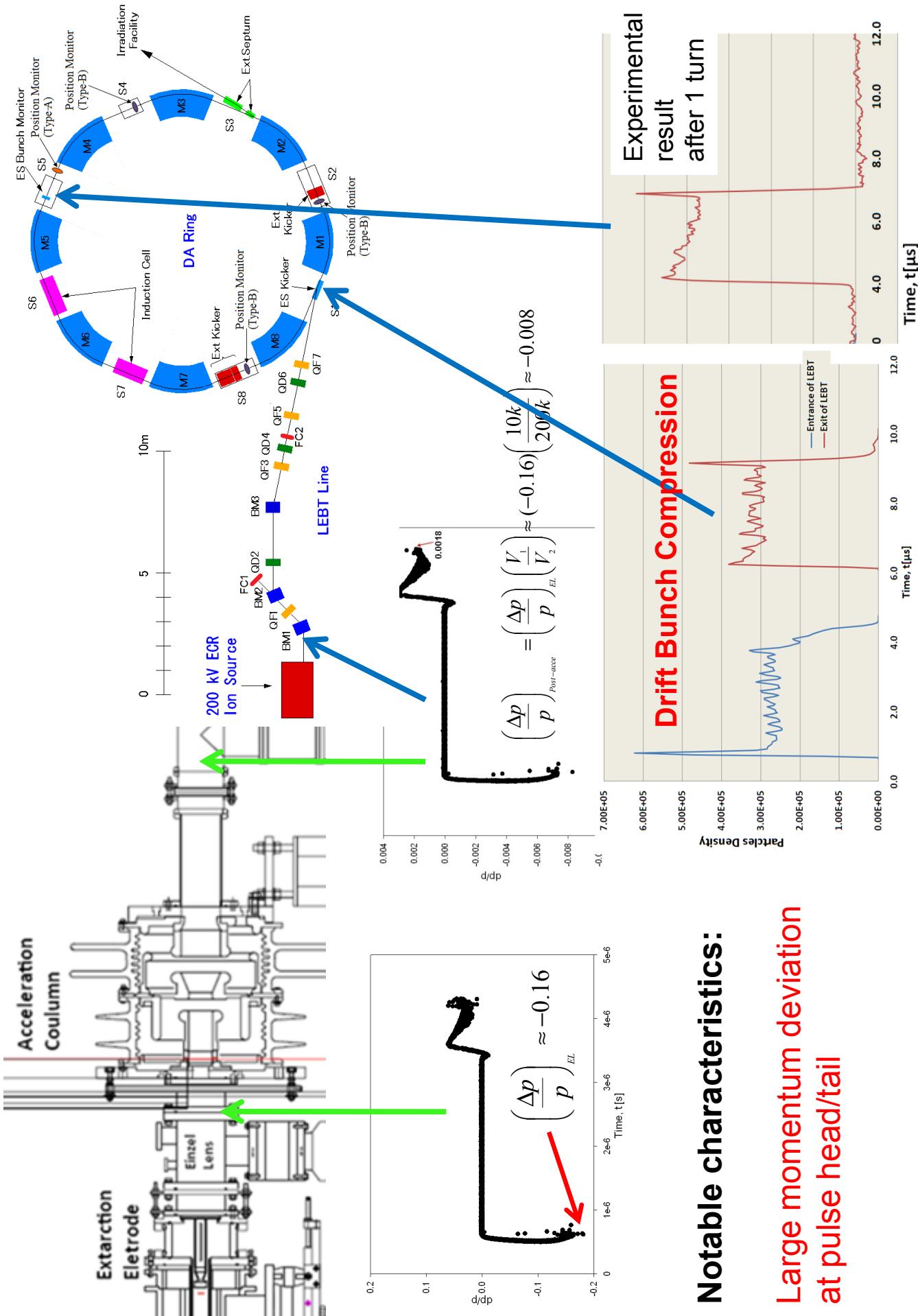


*motivated*

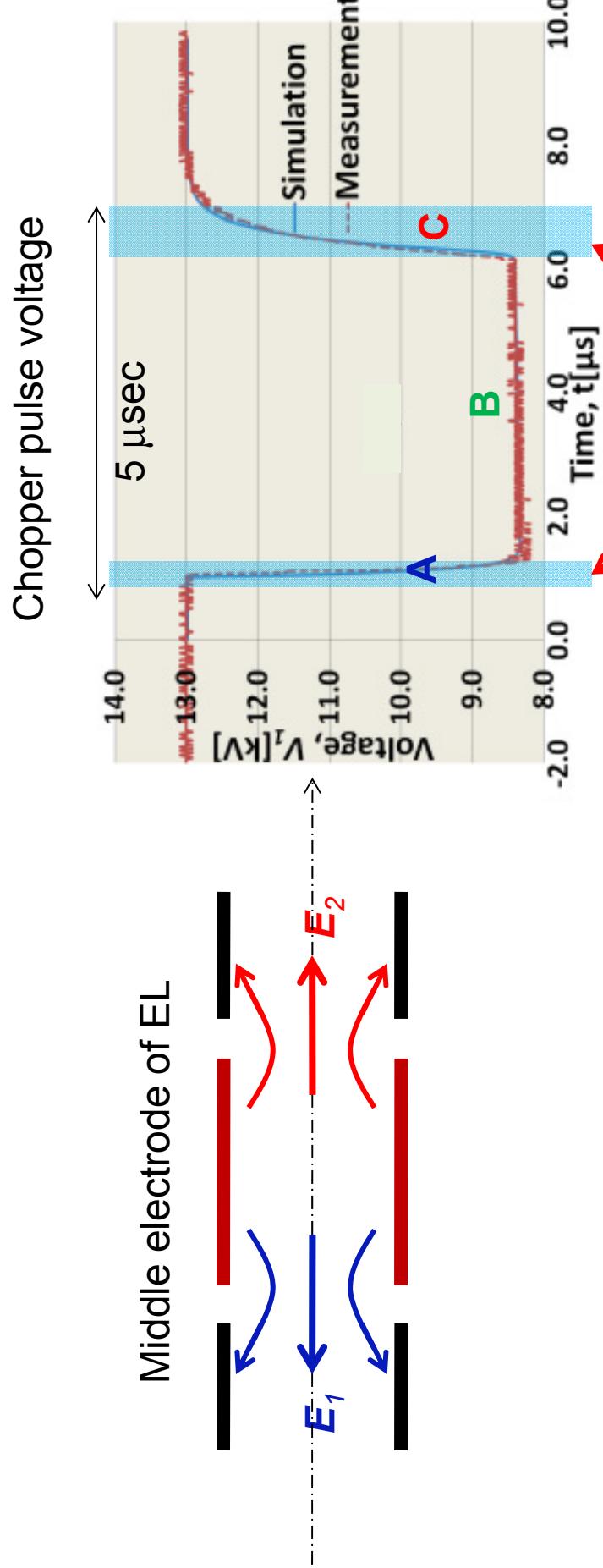
Simulation works to confirm what happens in the chopper region

Work by K.W. Leo

# Simulation Results



# Momentum Deviation and Temporal Change in Chopper Pulse Voltage



Let consider three particles of **A**, **B**, and **C**.

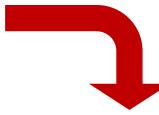
Transient time region

$E_1$  and  $E_2$  are electric fields exerting on specific particle **A**, **B** and **C** at the gaps.

Particle **A**: pass through the EL region during time region **A**, where  $|E_1| > |E_2| \rightarrow \Delta p/p < 0$

Particle **B**: pass through the EL region during time region **B**, where  $|E_1| = |E_2| \rightarrow \Delta p/p = 0$

Particle **C**: pass through the EL region during time region **C**, where  $|E_1| < |E_2| \rightarrow \Delta p/p > 0$



Momentum deviation in the chopped pulse

Intrinsic feature of the longitudinal chopper

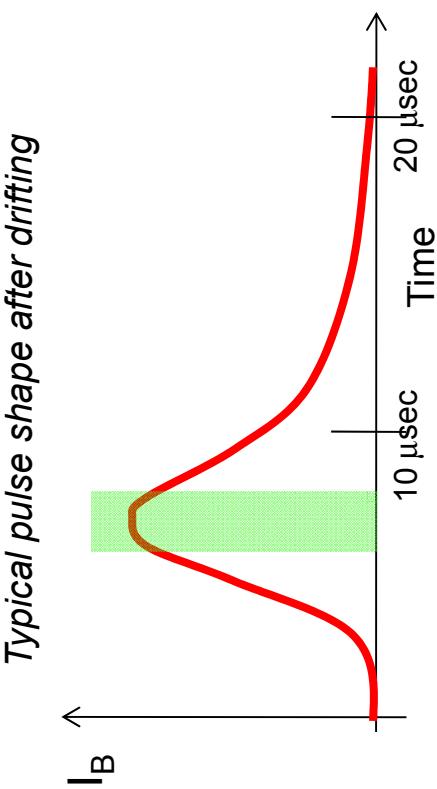
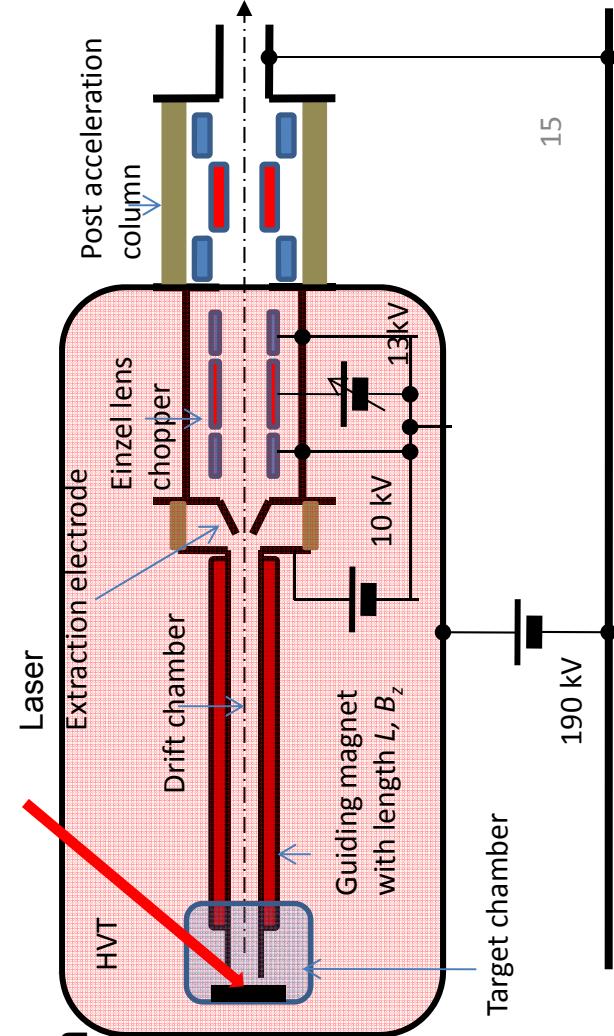
# Further Evolution and Application of the Einzel Lens Chopper are expected ?

## Possible evolution:

- Longer pulse chopper  
**Droop in pulse voltage** leads to degradation in current uniformity of a chopped beam.  
Limit on pulse length  
Measure → introducing **Droop compensation circuit**
- Fast rising/falling chopper with small momentum deviation  
**Transient time period of On/Off** is determined
  - (1) Switching time of solid-state switching element ( $\sim 5\text{-}10 \text{ nsec}$ )
  - (2) Stray capacitance ( $100 \text{ pF}$ ) of chopper head ( $\sim$  a few hundred nsec)Measure → **reduce the stray capacitance (practical limit from its geometry)**

## Applications: combination with other ion sources

- Laser ablation ion source  
chopping of an uniform beam fraction



# Summary

## ■ Performance of the Einzel Lens Longitudinal Beam Chopper has been confirmed.

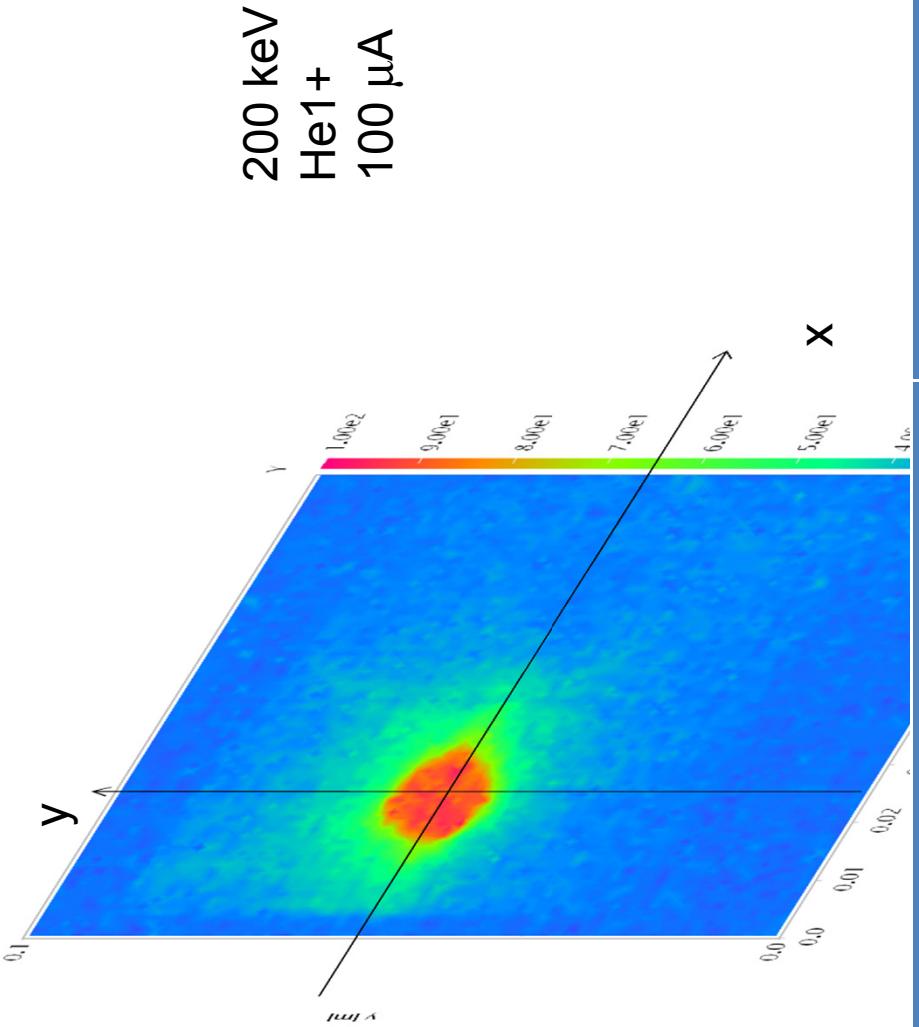
- Droop (< 2%) for 5 msec pulse with acceptable rising/falling time.
- Momentum modulation at **pulse head/tail** caused by a chopper voltage pulse with a finite time of rising/falling (still acceptable but this feature is generic in the ECL)
- Work without any trouble over one year for the KEK Digital Accelerator
- Following figure of merits are emphasized low voltage control, no specific chopper head, no extra space, no degradation of vacuum, low X-ray energy/dose, low secondary electrons, low cost (\$2.5K)

## ■ Further Improvements and for future Ion Source

- Additional correction circuit parameters for improvement of the droop.
- Minimize **stray capacitance** to get a more sharp chopper pulse
- Integration with Laser Ablation Ion Source (under test)

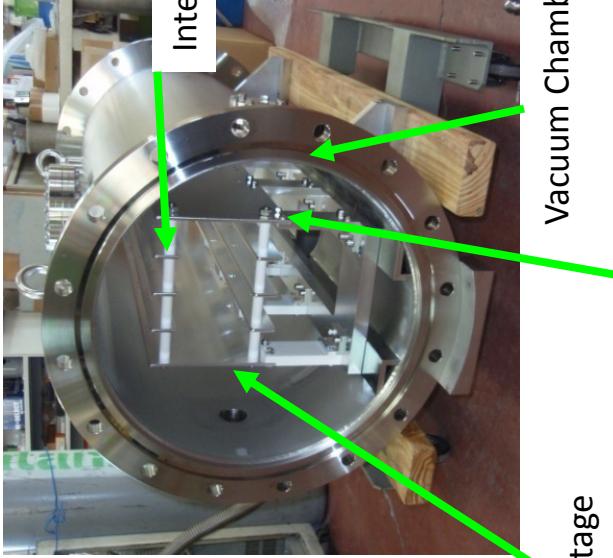
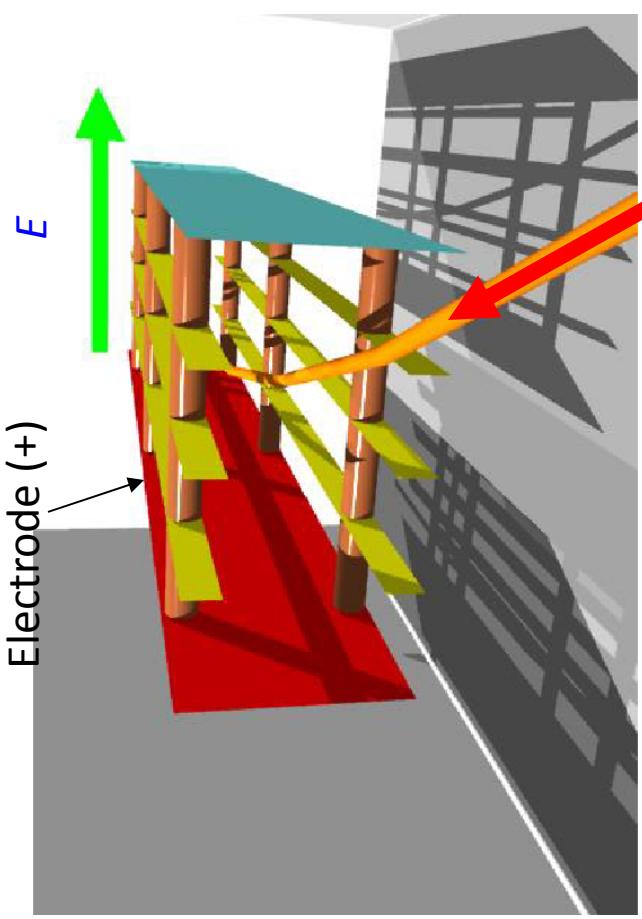
## Beam Profile on the Screen Monitor placed upstream in LEBT

Beam profile plotted by the result from “Screen Monitor”

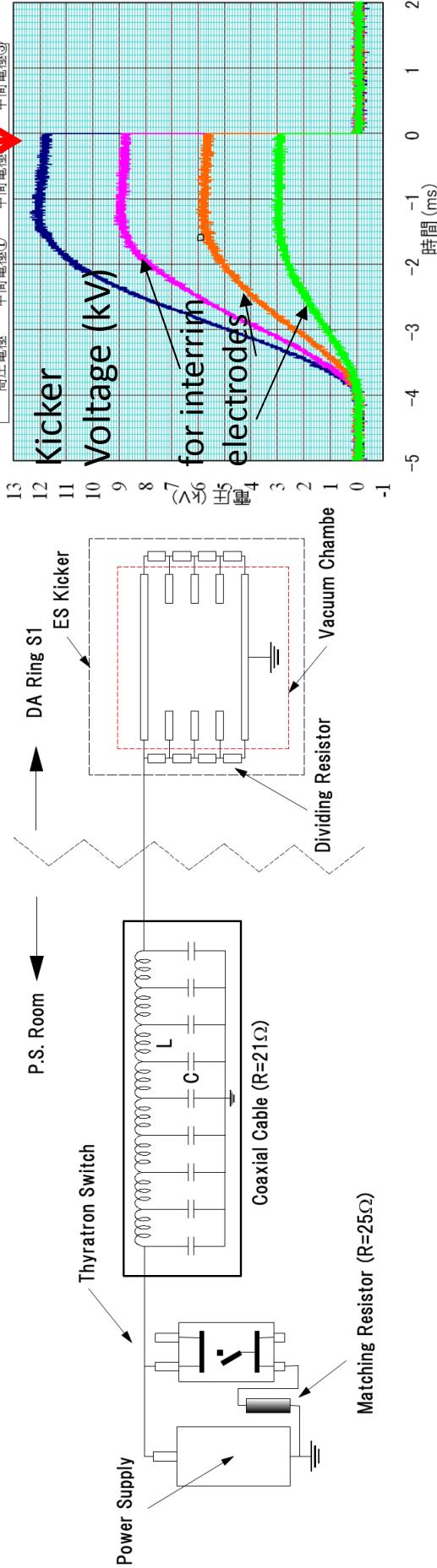


Measurement by Pepper pot device	Horizontal rms emittance $\epsilon_x [\mu\text{mrad}]$	$\sim 100$
	Vertical rms emittance, $\epsilon_y [\mu\text{mrad}]$	$\sim 75$

# Electrostatic Injection Kicker



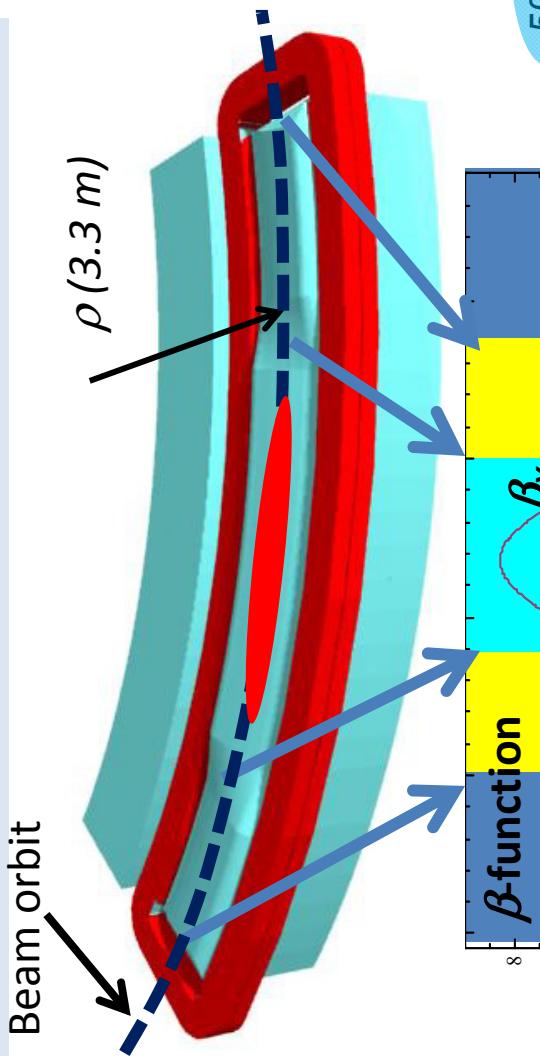
## Driving circuit of the injection ES kicker



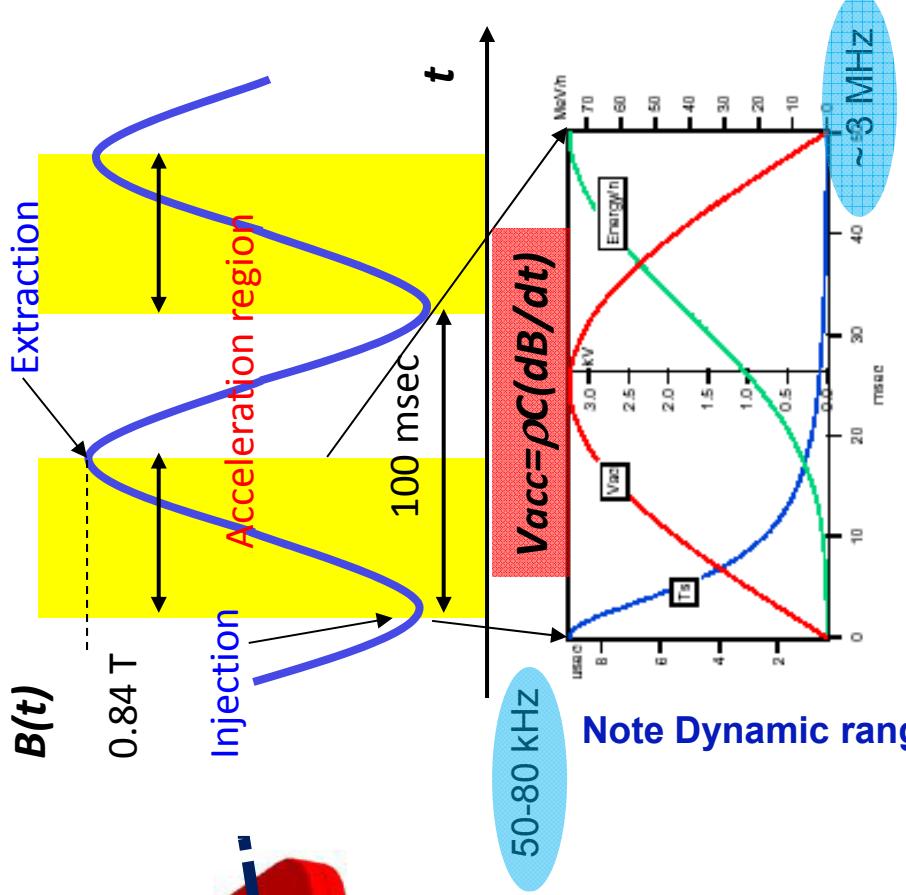
## Injection timing

# DA Ring Machine & Beam Parameters

## Combined-function type magnet (lower half)



## Field ramping and acceleration



Ring circumference	$C_0$	37.7 m
Maximum flux density	$B_{max}$	0.84 T
Accel. voltage/turn	$V$	3.24 kV
Repetition rate	$f$	10 Hz
Betatron tune	$\nu_x/\nu_y$	2.17/2.3